

REMARKS

Prior to the present Response, the present Application contained Claim 1. Through this Response, no claims have been added, amended or canceled. Accordingly, following the entry of this Response, the Claim 1 will be pending in the present application. Applicant respectfully requests reconsideration of the present application based on the following remarks.

Claim 1 stands rejected under 35 U.S.C. §112, first paragraph, as failing to comply with the written description requirement. Applicant respectfully traverses the rejection.

The Examiner refers to the language in the specification at page 22, lines 20-24, which discloses that the angle between the outer wall of a tapered portion 76b of a gate electrode 76 and the surface of the insulator substrate 71 is set within a range of 5 and 40 degrees, and states that no support is present for the angle between each of the inclined surfaces of the second pair of tapered end portions of the supplemental capacitor electrode. Applicant submits that the specification contains support for Claim 1. Such support can be found, at least, at page 15, line 25 to page 16, line 4, Figure 9, and the accompanying text related to Fig. 9. More specifically, the fabrication of the supplemental capacitor and thin film transistor is described as being completed through the same processing steps. For example, at page 15, line 27-28, the specification states "The supplemental capacitor SC is formed in the same step as the TFT 206." Accordingly, because the supplemental capacitor is formed during the same step, and has the same component layers as the TFT, the tapered end portions of the supplemental capacitor will have substantially the same angle as the gate electrode. Similarly, at page 4, line 25 to page 5, line 18, the present specification discloses the forming of a gate electrode and supplemental capacitor by etching at the same time. Therefore,

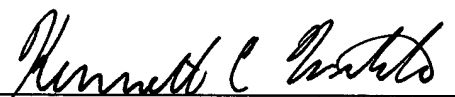
Application No. 09/730,875

Applicant submits that the specification discloses the angle of the supplemental capacitor electrode as being the same as that of the gate electrode.

Based upon the foregoing, Applicant believes that the pending claim is in condition for allowance and such disposition is respectfully requested. In the event that a telephone conversation would further prosecution and/or expedite allowance, the Examiner is invited to contact the undersigned.

Respectfully submitted,

SHERIDAN ROSS P.C.

By: 

Kenneth C. Winterton
Registration No. 48,040
1560 Broadway, Suite 1200
Denver, Colorado 80202-5141
(303) 863-9700

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